2nd International Workshop on Proton-Boron Fusion



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Pulsed laser deposition of boron-based targets for p-¹¹B studies



Davide Orecchia

Catania, 7/9/2022



Overview



Introduction



Targets for p-¹¹B studies



Pulsed Laser Deposition (PLD) as a flexible technique



Compact boron films



Application to p-11B cross section studies



Low density boron nanofoams



Conclusion and perspectives





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techniques

adapted from Harilal S.S. et al., in "Laser-induced breakdown spectroscopy", ch. 6, 2014

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Compact boron films with ns-PLD



Deposition parameters:

- ns-PLD (532 nm, 7 ns)
- High vacuum $(10^{-3} 10^{-4} \text{ Pa})$
- High fluence $(8 9 \text{ J/cm}^2)$
- Tradeoff target-substrate distance (6 – 9 cm)

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Higher targetsubstrate distance





Film properties:

Solid density (~ 2.35 g/cm³) Compact film with few defects 100s nm - 10 μm thickness

Match the experimental needs



Compact boron films with ns-PLD

Limitations:



Substrate heating

Natural boron target with
Mg impurities (~ 2%)







Amorphous films

Residual stresses

2.3 J/cm²

200 nm



5.1 J/cm

- Pulse energy & fluence



b

200 nm

Dellasega D. et al., Materials & Design 134, 2017

High fluence



С

2<u>00 nm</u>

Application: p-¹¹B cross section investigation

Open points in the physics of the reaction, especially at **low energies**

 $\hat{\Gamma}$

- Cross section
- α particle energy and angle distribution



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Fundamental for applications

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Proton accelerator

@ INFN – LaboratoriNazionali di Legnaro

Mazzucconi D. et al., submitted to Radiation Physics and Chemistry







- Well characterized in density and composition
- Variable thickness





Mazzucconi D. et al., Physica Medica 89, 2021

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Radiation Physics and Chemistry





Density

Deposition parameters:

• **fs-PLD** (800 nm, 80 fs)

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- Background argon gas pressure (~ 100s Pa)
- "High" fluence (~ 0.1 J/cm²)
- Low target-substrate distance (~ 3 cm)

Film properties:

- Low average density, down to $\sim 15 \text{ mg/cm}^3$
- 🔹 10 μm ~100 μm thickness 📿
- ~ 2% Mg impurities and ~ 20% oxygen content
- Uniformity scale of $\sim 10 \ \mu m$

Freedom in material choice



Hydrogen enrichment

Conclusions and perspectives

Boron nanofoams









200 nm



Compact boron films



ns-PLD fs-PLD

Versatile and flexible for boron target production

Isotopic ¹¹B, BN, plastic targets for PLD Improve the material properties control

Employ the targets in p-¹¹B fusion experiments

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Thank you for your attention!





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